

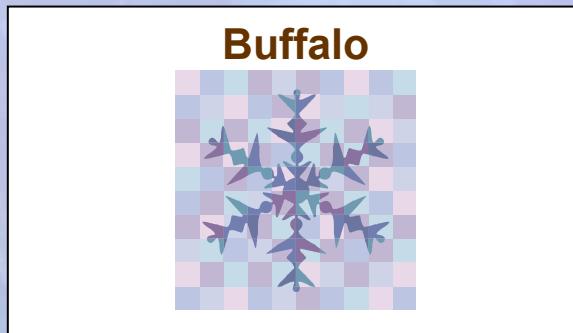
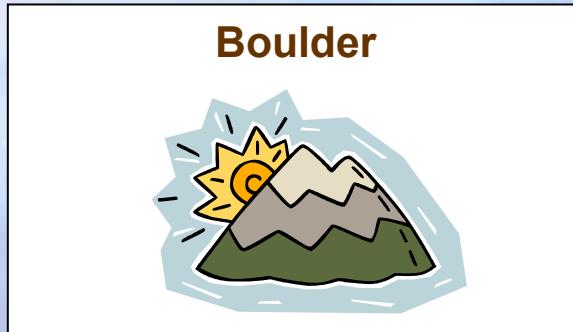
Vacuum Electronics and the World Above 100 GHz



Mark Rosker, DARPA/MTO
International Vacuum Electronics Conference
Monterey, CA
22 April 2008

A THz Atlas: The 6 B's

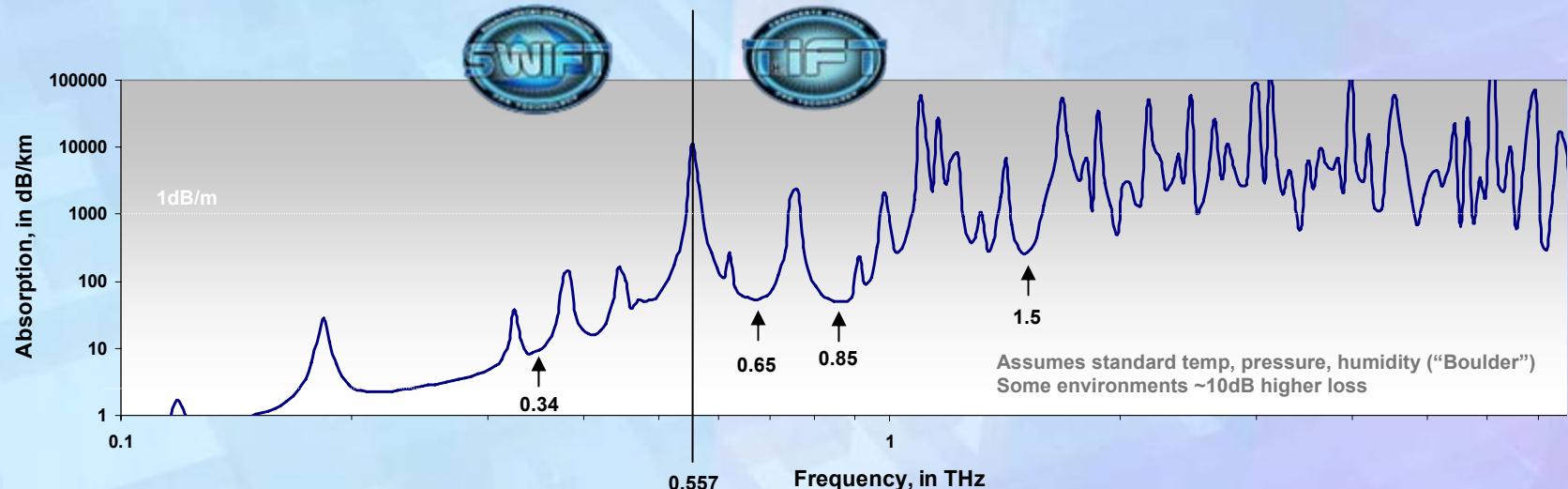
Increasing THz Absorption ↑



↓ Decreasing THz Absorption

MTO's THz Programs

Phenomenology

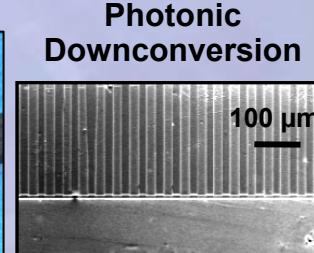
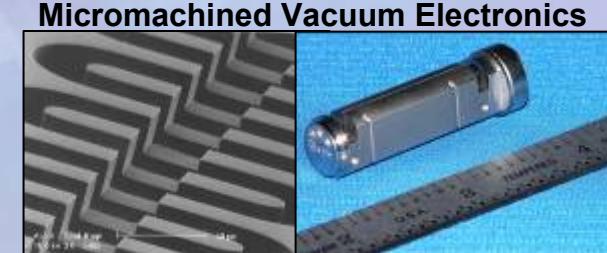
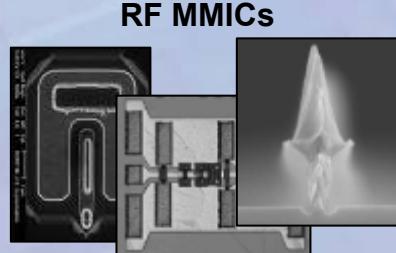


↓

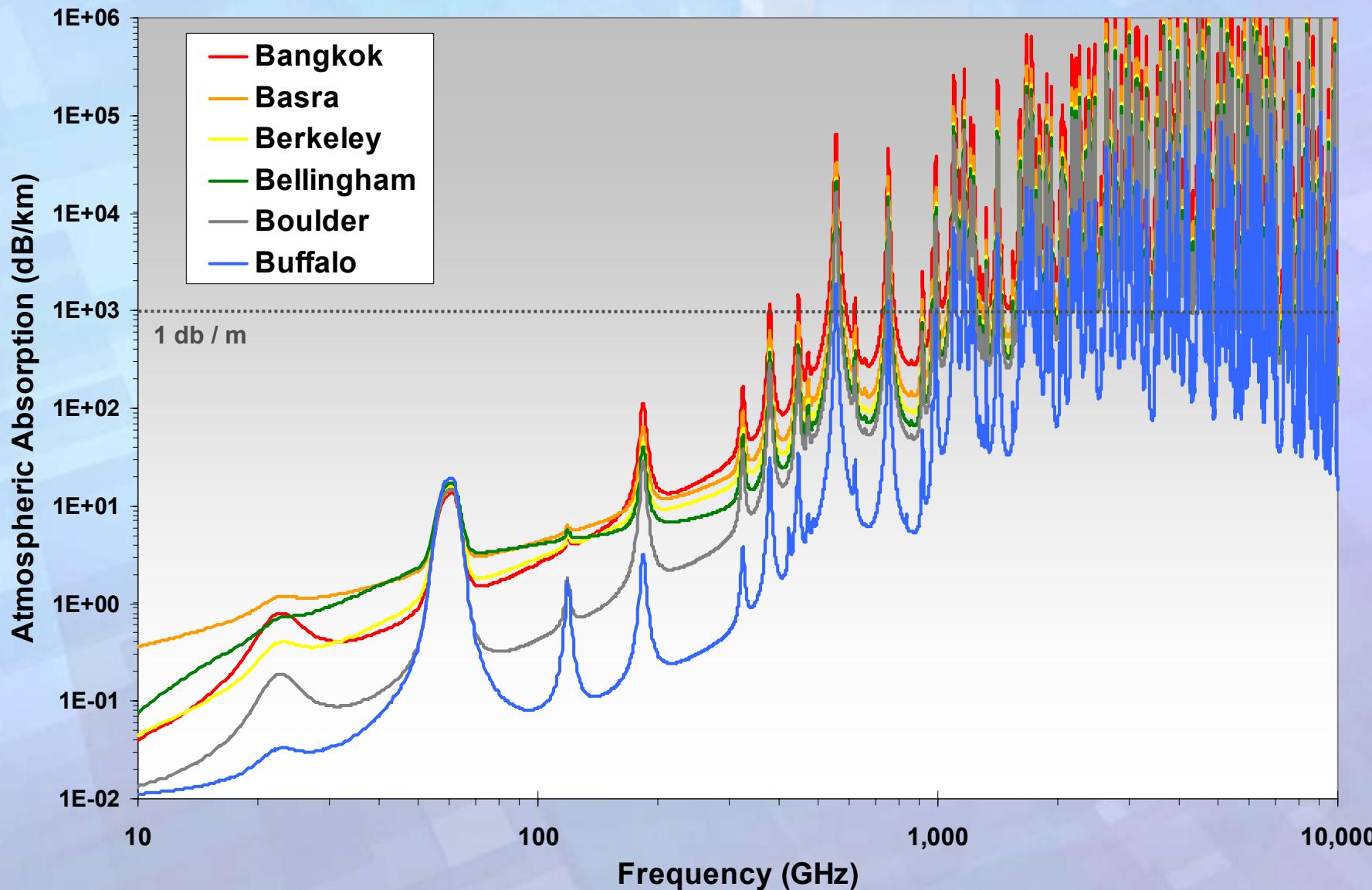
Applications



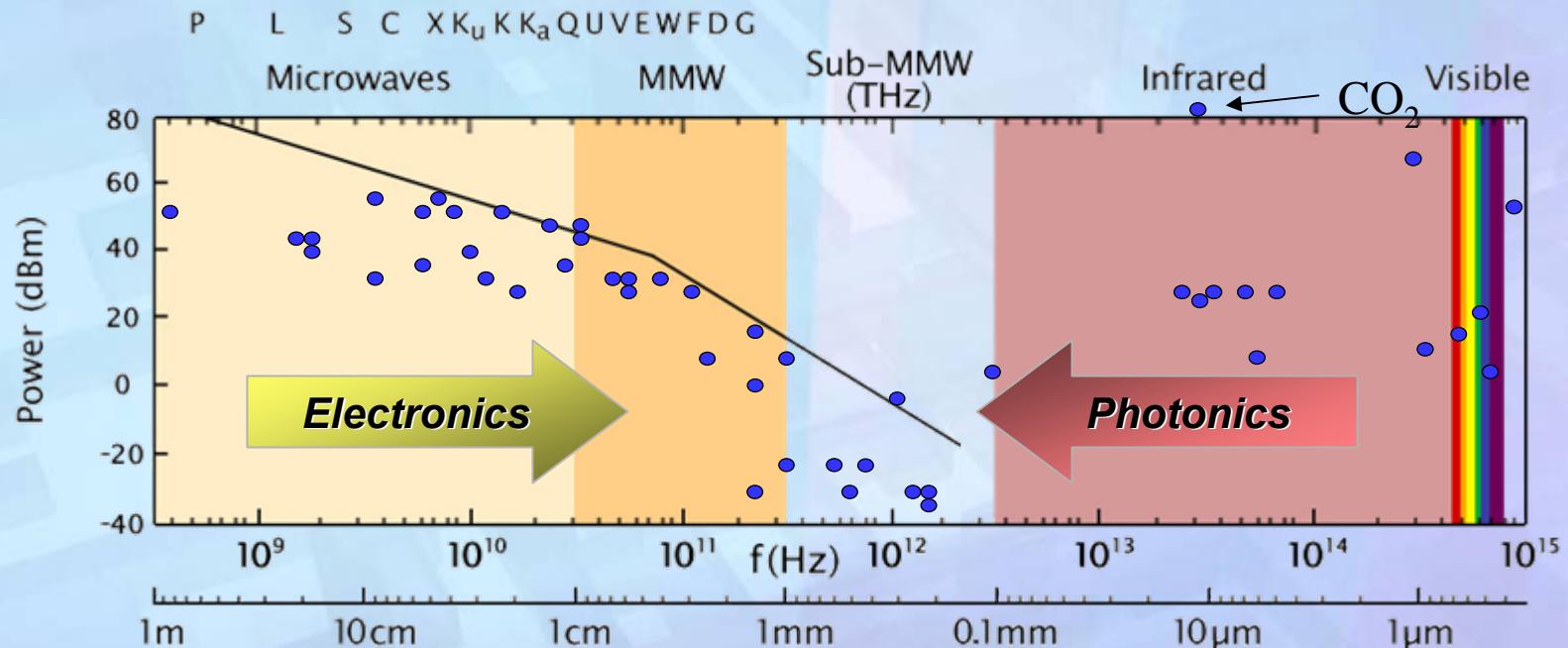
Technologies



Compiled Atmospheric Models



The “THz Gap”



Electronics

- Classical region ($h\nu \ll kT$)
- Critical dimensions $\ll \lambda$
- Atmosphere transparent
- Sources readily available

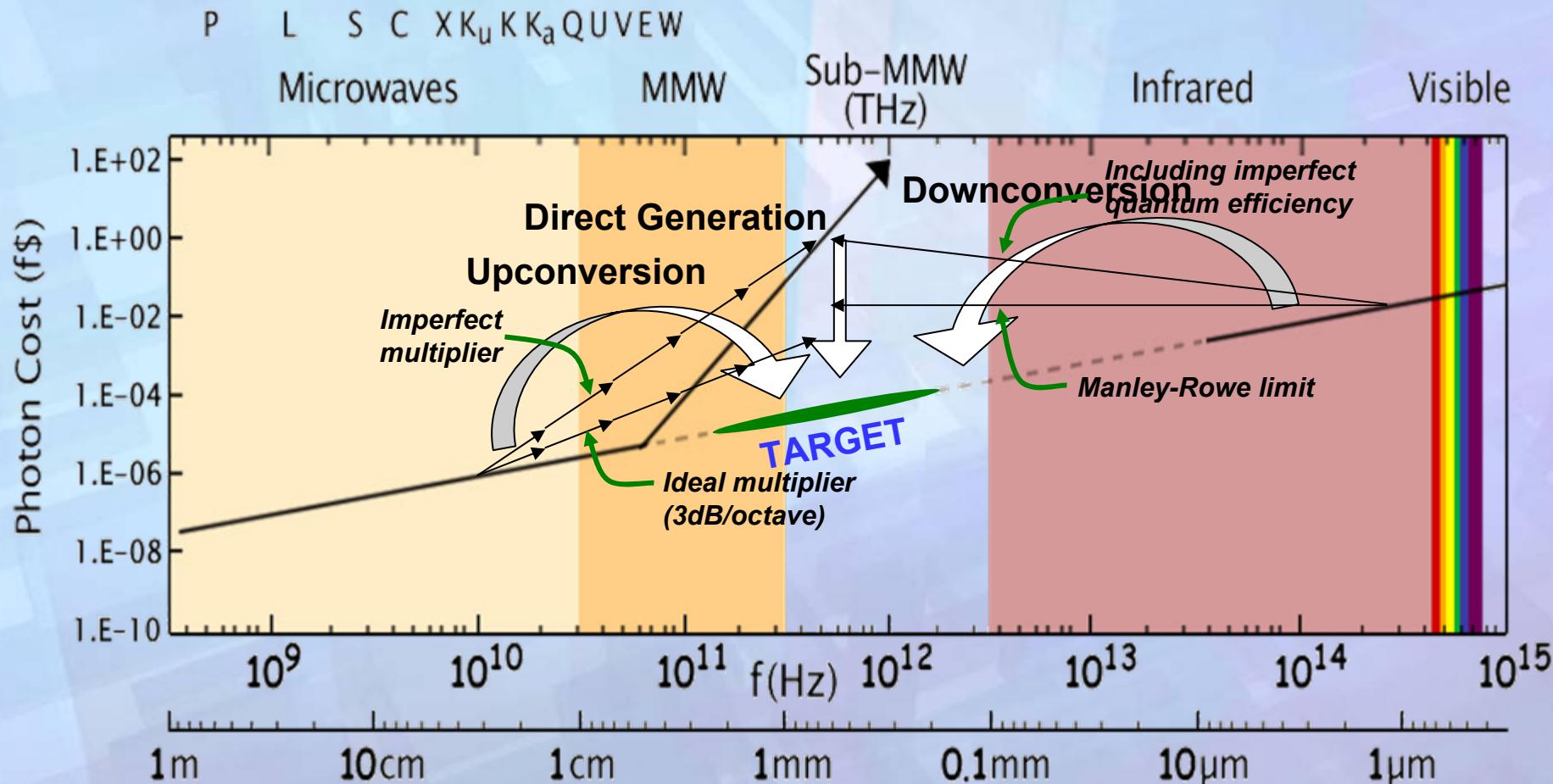
THz / Sub MMW

- Transition region: $h\nu \sim kT$
- Narrow, poor transparency windows
- Only weak sources available

Optics

- Quantum region ($h\nu \gg kT$)
- Critical dimensions $> \lambda$
- Atmosphere transparent
- Sources available (many at specific λ)

How Much Is that Photon? (The Rosker Chart)

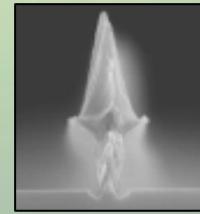
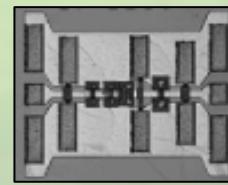


(Some) Source Approaches

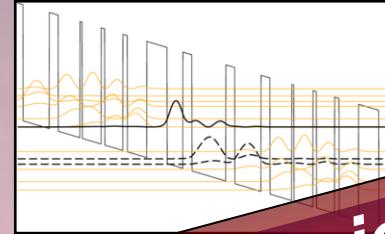
Electronics

Photonics

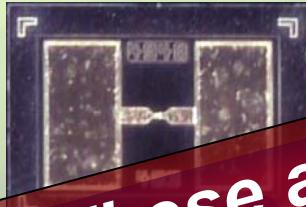
Transistors



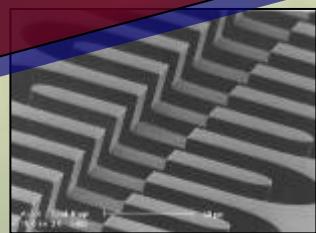
Lasers



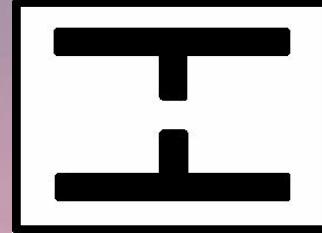
Diodes



Vacuum Electronics

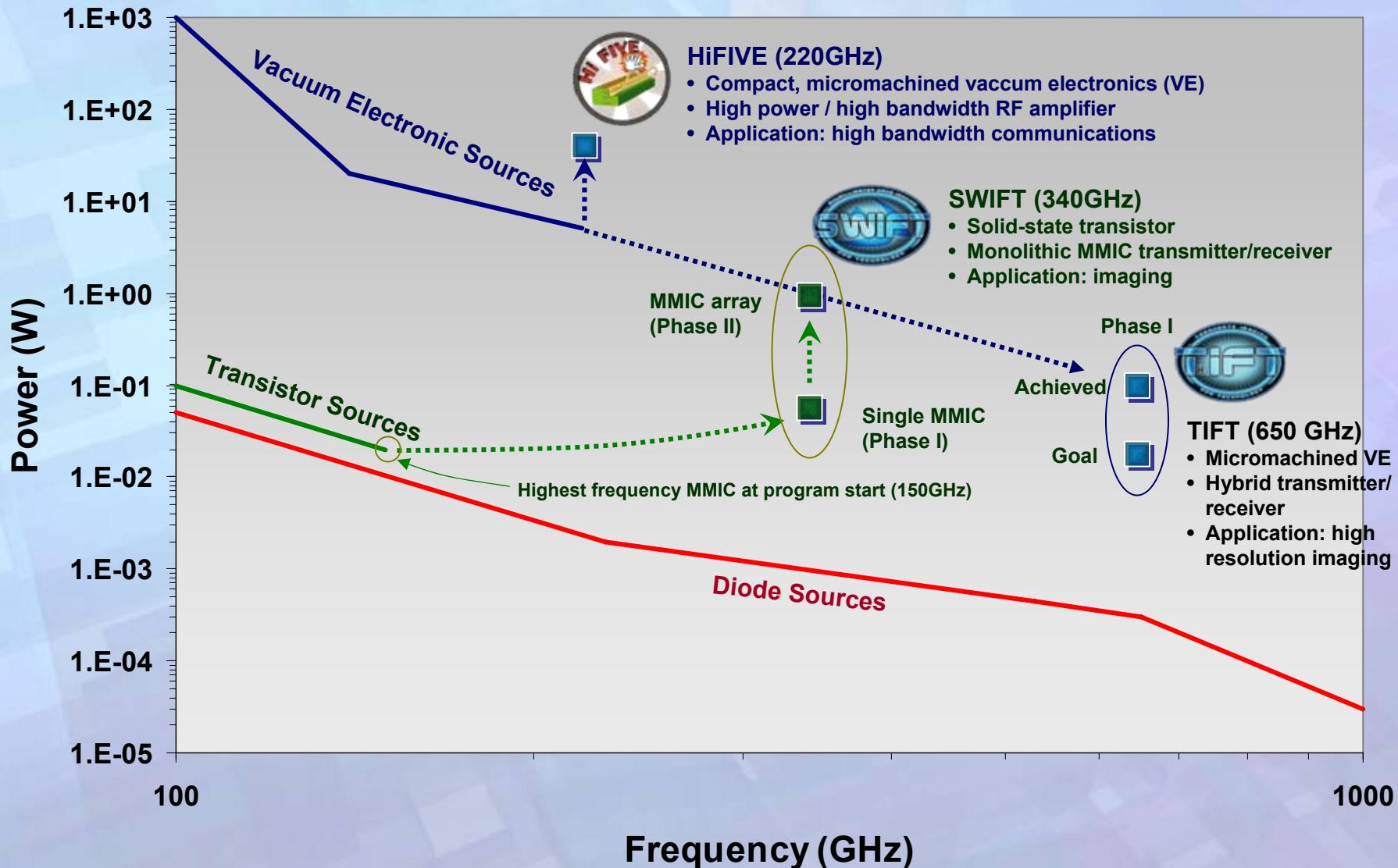


Photoconductive



*These are not just different technologies;
they are different communities*

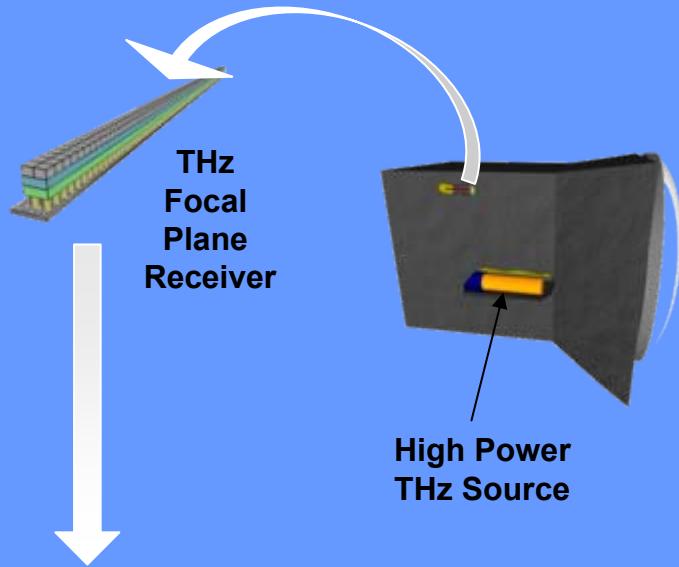
Sources Above 100GHz



TIFT



Terahertz Imaging Focal-Plane Technology (TIIFT)



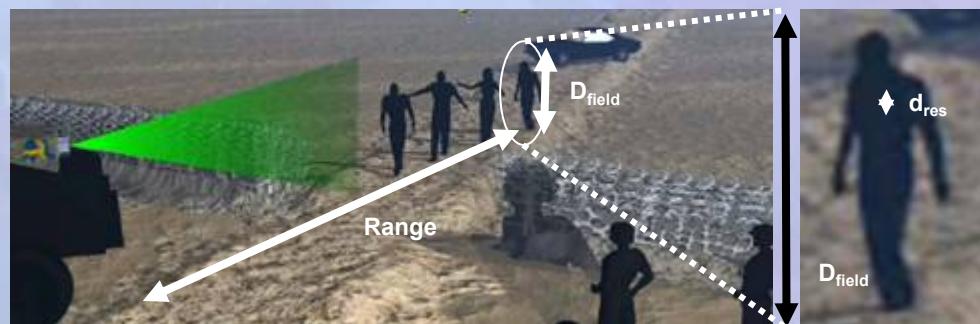
Components for THz Imaging

Program Objective:

- Achieve revolutionary advances in THz transmit and receive technology
- Develop building blocks to enable compact THz (>557 GHz) sensor arrays for diffraction-limited, video-rate imaging

DoD Benefits

- Spectral dominance: will enable exploitation of currently inaccessible region of EM spectrum
- Will develop components needed to enable practical THz systems (sensing, secure communications, spectroscopy, concealed weapons detection)

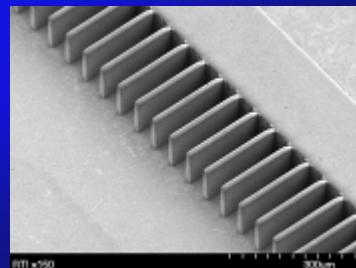


Concealed Weapons Detection at Moderate Range

Technical Challenges

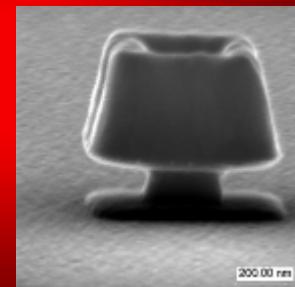
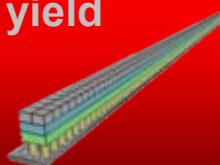
THz Transmitters

- Higher P_{out}
 - Parasitic loss reduction
 - Circuit feedback optimization
 - Emitter optimization
- High bandwidth
- Thermal management
- Uniformity
- Modulation



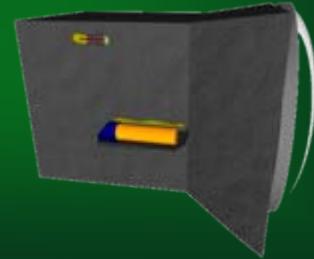
THz Array Receivers

- Integration while maintaining detector sensitivity and minimizing LO power
- Dynamic range
- THz distribution
- Uniformity / yield
- Modulation



THz Active Imagers

- Integration of transmit with receive with minimal losses
- Video rate readout
- Calibration
- Scanning



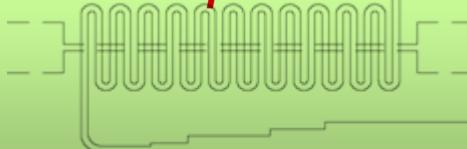
Technical Goals

Sources

- Increase available sub-MMW power to 10mW, with a path to 100mW (10 to 100X increase*)
- Achieve 1% wallplug efficiency (nearly 100X increase*)

Micromachined Vacuum Electronics^f

Northrop Grumman



Regenerative Amplifier

Detectors

- Implement an array-integrable approach achieving NEP' of 1×10^{-12} W/ $\sqrt{\text{Hz}}$ (> 100X improvement*)

Direct Detectors

**UC
Santa
Barbara**



ErAs Diodes

^f Work on diamond BWO by GENVAC Aerospace also supported by SBIR funding

Photonic Downconversion

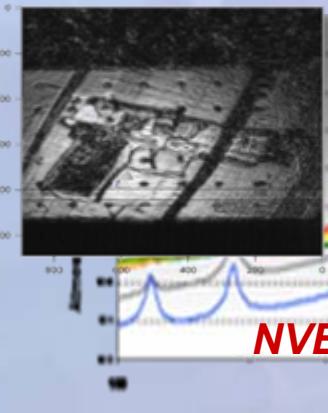
Stanford



Cascaded OPO

Phenomenology & System Model

- Define FPA requirements for TIFT imaging through IR-blind conditions



THz transmission through materials/atmosphere

NVESD / Ohio State



Spectral Features of Condensed Matter

*Comparisons referenced to 0.65THz

TIFT Accomplishments

THz Source Technology

World's first THz micromachined vacuum electronics source



Tunable downconversion source with ~25 dB greater power than SOA at 1.5THz

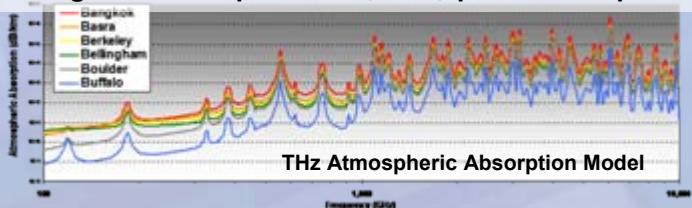


THz Phenomenology

Measured THz transmission through clothing and building materials

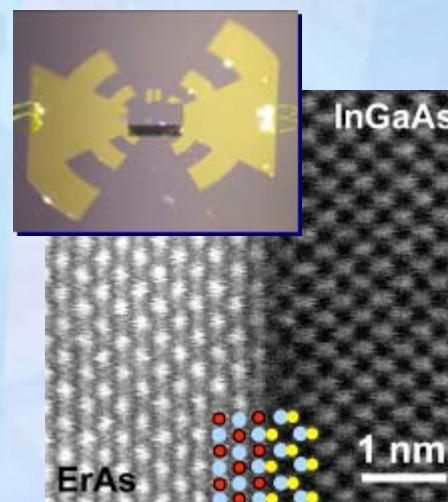


Compiled a single inclusive parametric atmospheric absorption model

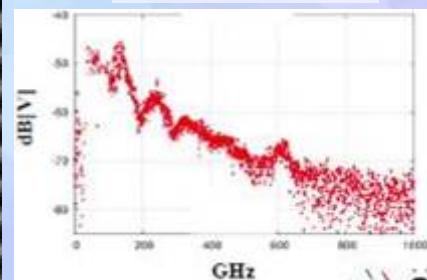


THz Detector Technology

World's most sensitive THz direct detection receiver

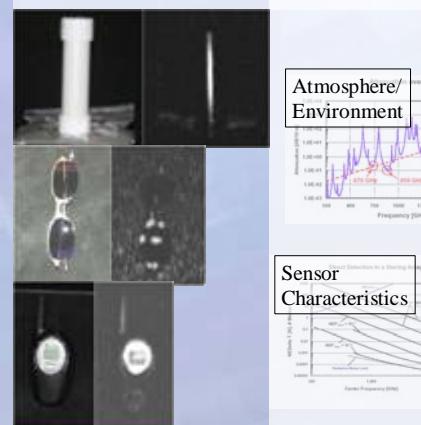


4.5 pW/√Hz at 640 GHz

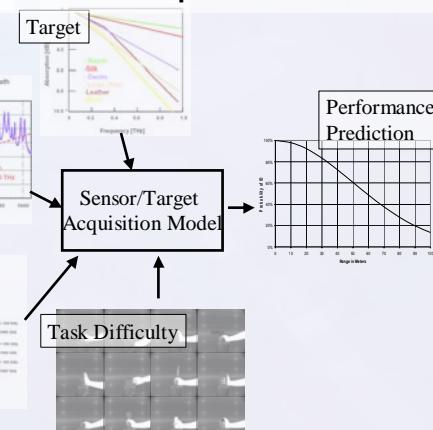


THz System Model

Extended NVESD IR perception model to THz using THz images

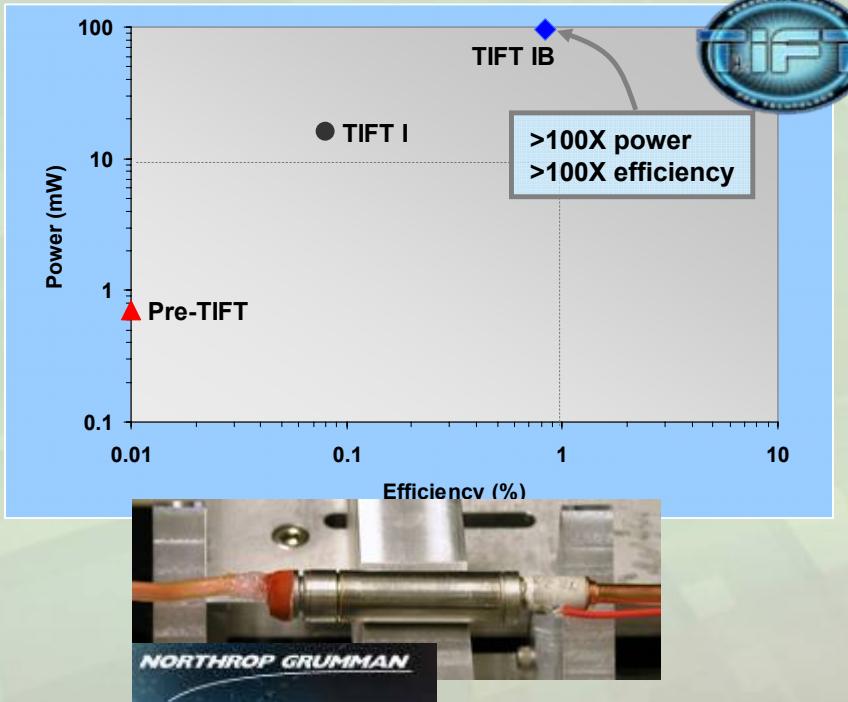


Constructed THz imager architecture performance model

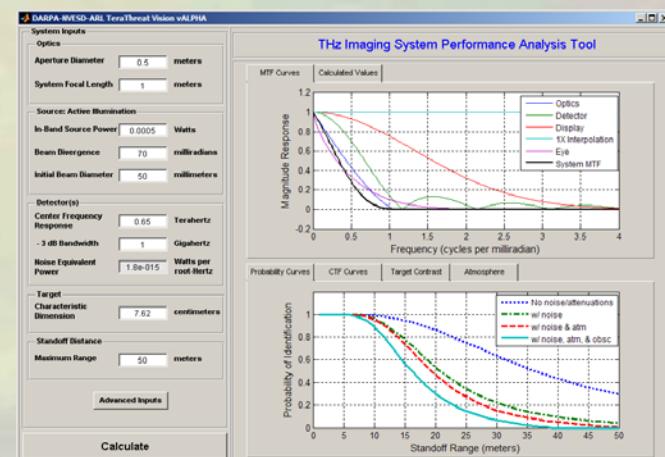


TIFT Performers

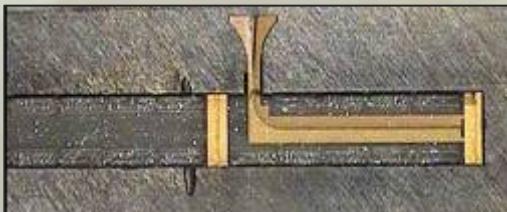
NGC: Micromachined TWT regenerative amplifier



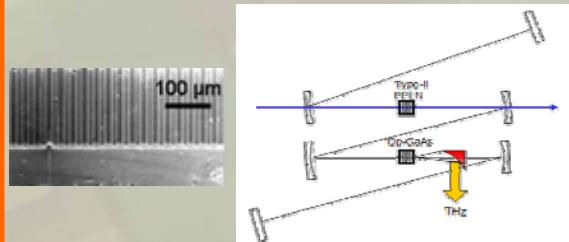
NVESD: THz Imaging Phenomenology and System Performance Model



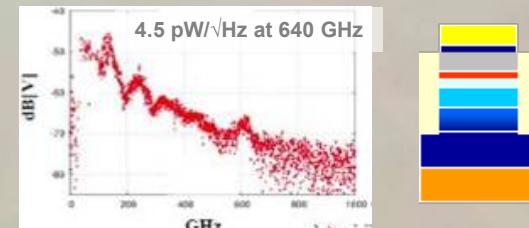
Genvac: Wafer scale manufacturing of diamond and gold BWOs



Stanford: Cascaded optical down-conversion based source at 1.5 THz



UCSB: Single-crystal ErAs:InGaAlAs rectifier based direct detectors





TIFT Metrics

Metric		Unit	Pre – Program SOA	TIFT	
				Result	Goal
	Operating frequency	GHz		>557	
Source	Power	mW	0.7	98	16 ⁽¹⁾
	Efficiency	%	0.01	0.83	1.0
	Duty cycle	%	N/A	3	50
	Bandwidth ⁽²⁾	GHz	30	61*	15
	Direct detect	pW/ $\sqrt{\text{Hz}}$	500	4	1
Receiver	Dynamic range	dB		70	80
	FPA size	elements		1 [†]	16

(1) Should demonstrate a path to 100mW

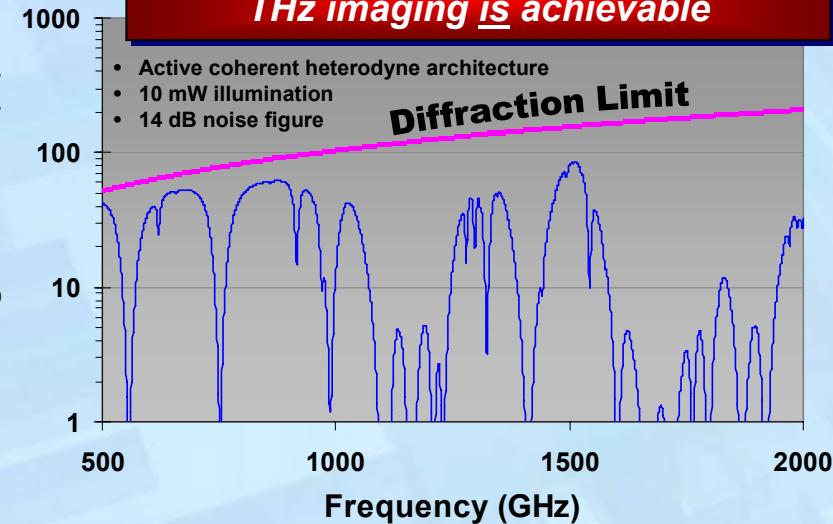
(2) Measured over an integration time of 1μs

* Value is extrapolated from DC measurements

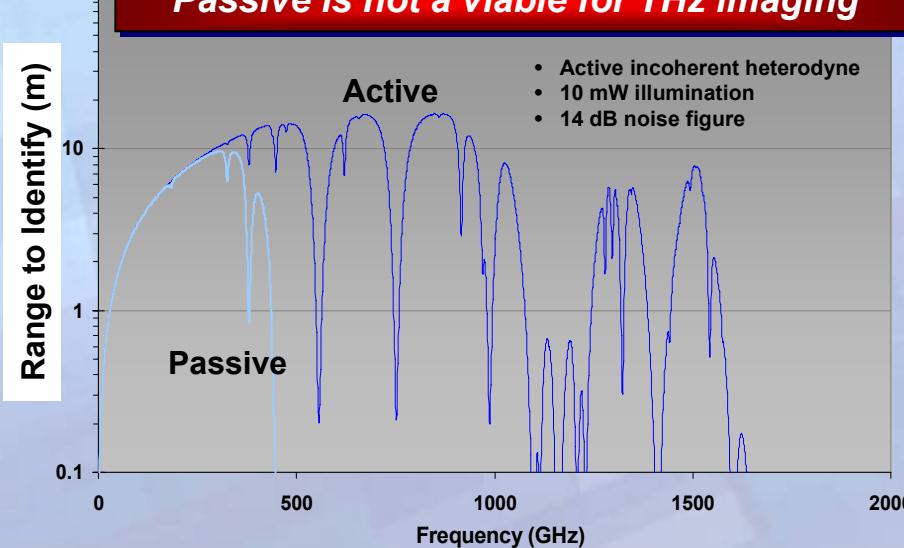
† Largest size tested

Lessons Learned from TIFT

Near-diffraction limit, video-rate THz imaging is achievable



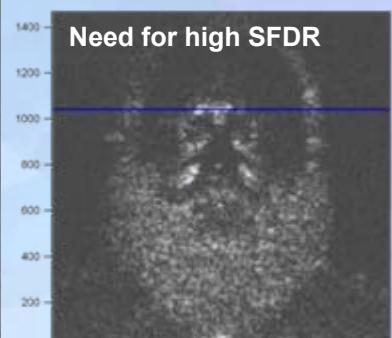
Passive is not a viable for THz imaging



Need for wide modulation

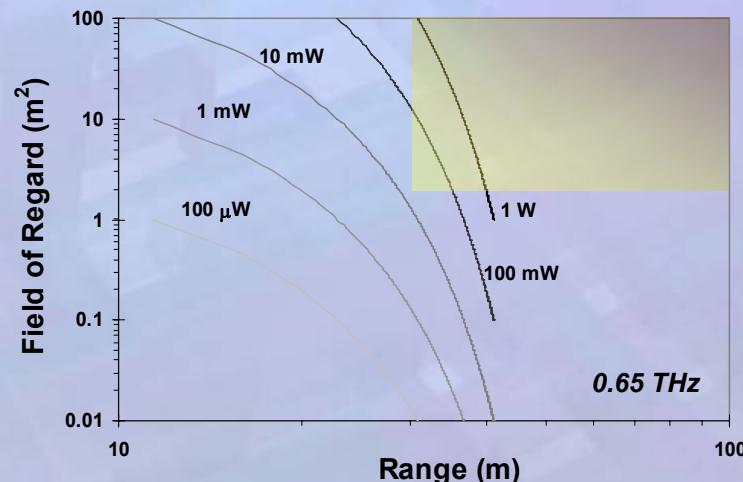


Need for high SFDR



Transmit / receive must satisfy challenging new bandwidth and dynamic range requirements

Total illumination power requirements set by field of regard, not by range



SWIFT



SWIFT Objective and Impact

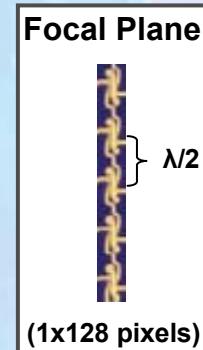
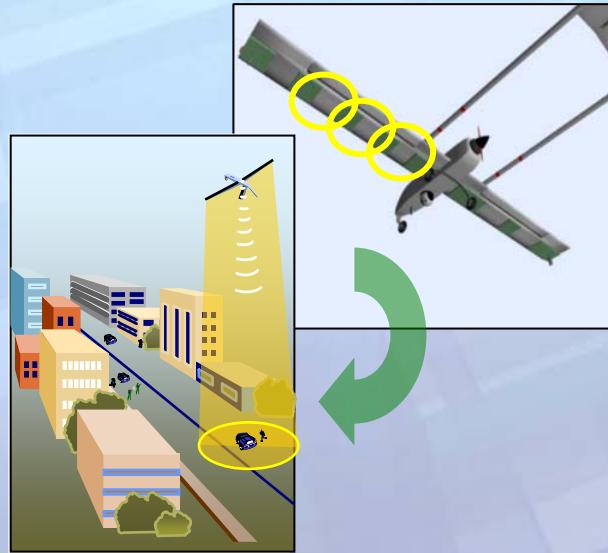
Goal

- Demonstrate high-performance transmit/receive sub-aperture to enable diffraction-limited and video-rate sub-MMW (340 GHz) imaging

Impact

- Push the limits of RF electronics
- Enable imaging in environments where no other sensor can function

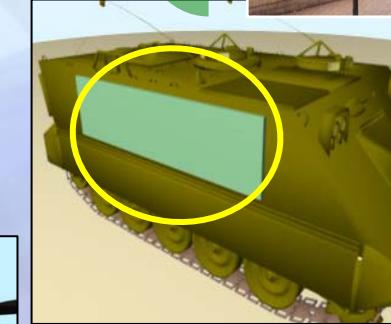
All-Weather Look-Down ISR



Concealed Weapons Detection at Range



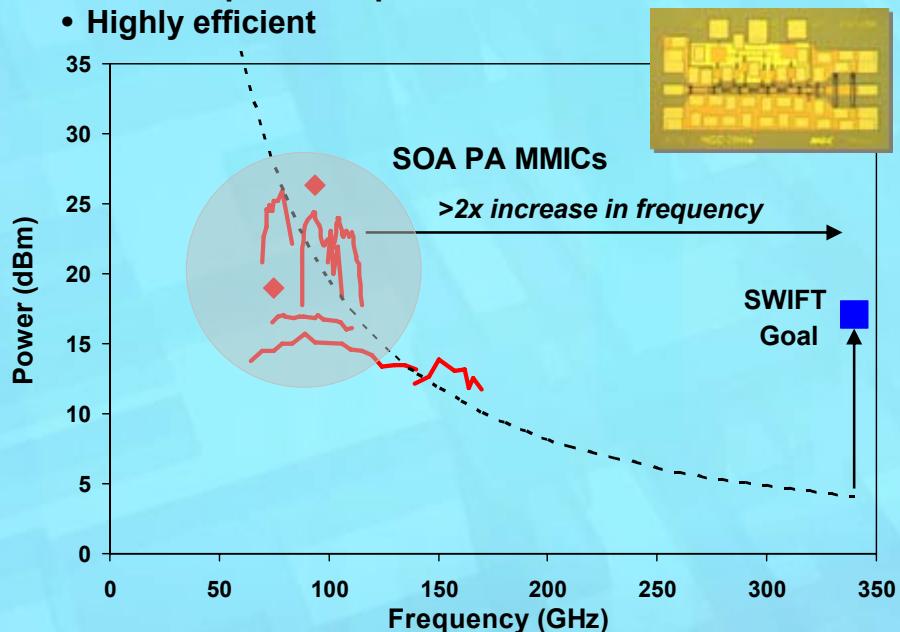
All-Weather Terrain Avoidance



SWIFT Technical Challenges

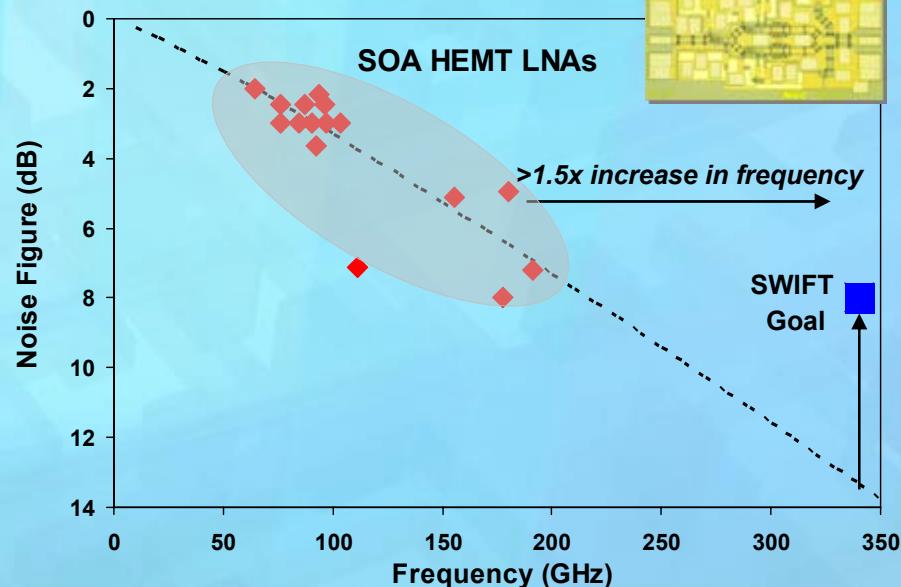
Sub-MMW Sources

- Ultrafast power amplifier MMICs
- Highly efficient



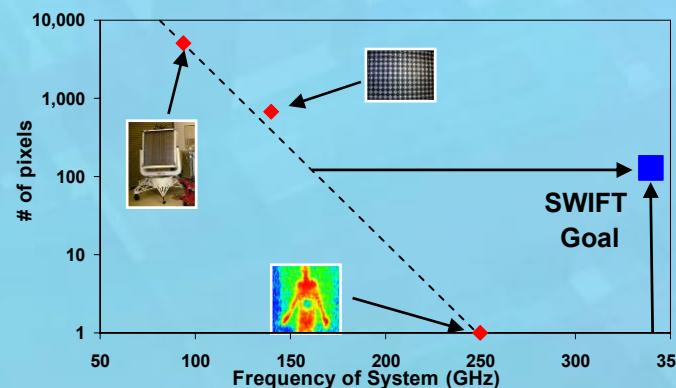
Sub-MMW Receivers

- Ultrafast LNA MMICs and mixers
- Low noise figure receiver



Imaging Array Architecture

- Minimization of LO power
- Low loss interconnects





SWIFT Program Metrics

Metric*	Unit	Today	Phase I		Phase II
			Mid-term MMIC Demo	MMIC GNG	Sub-Aperture GNG
PA P _{out}	mW	None**	5	50	
PA PAE	%	None	2.5	5	
RF bandwidth	%	None	≥ 5	≥ 5	
Receiver NF	dB	None**	12	8	
Phase noise ‡	dBc/Hz	None	-38	-38	
Transmit power	mW	N/A			1000
Sub-array receiver NF	dB	N/A			8
Level of integration	pixels	N/A			128
Frame rate	Hz	N/A			30
Receiver LO power	mW	N/A			< 500

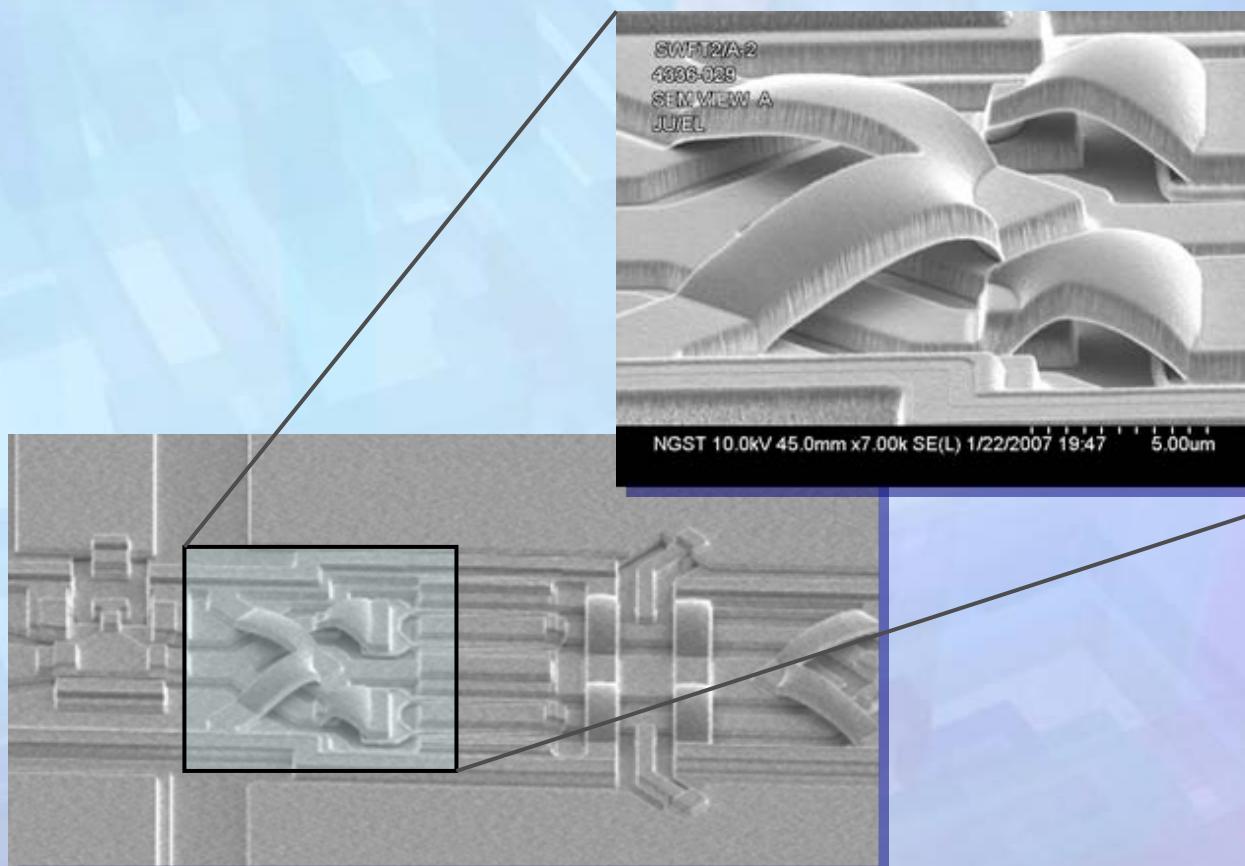
* At 340GHz

** Best reported value for hybrid PA power/LNA NF at 340 GHz are 0.1 mW and 12 dB, respectively

† Azimuthal (height) x cross-track (width)

‡ Value to be measured at $f_c = 340\text{GHz}$ at offset frequency of 100Hz

What Does an s-MMIC Look Like?

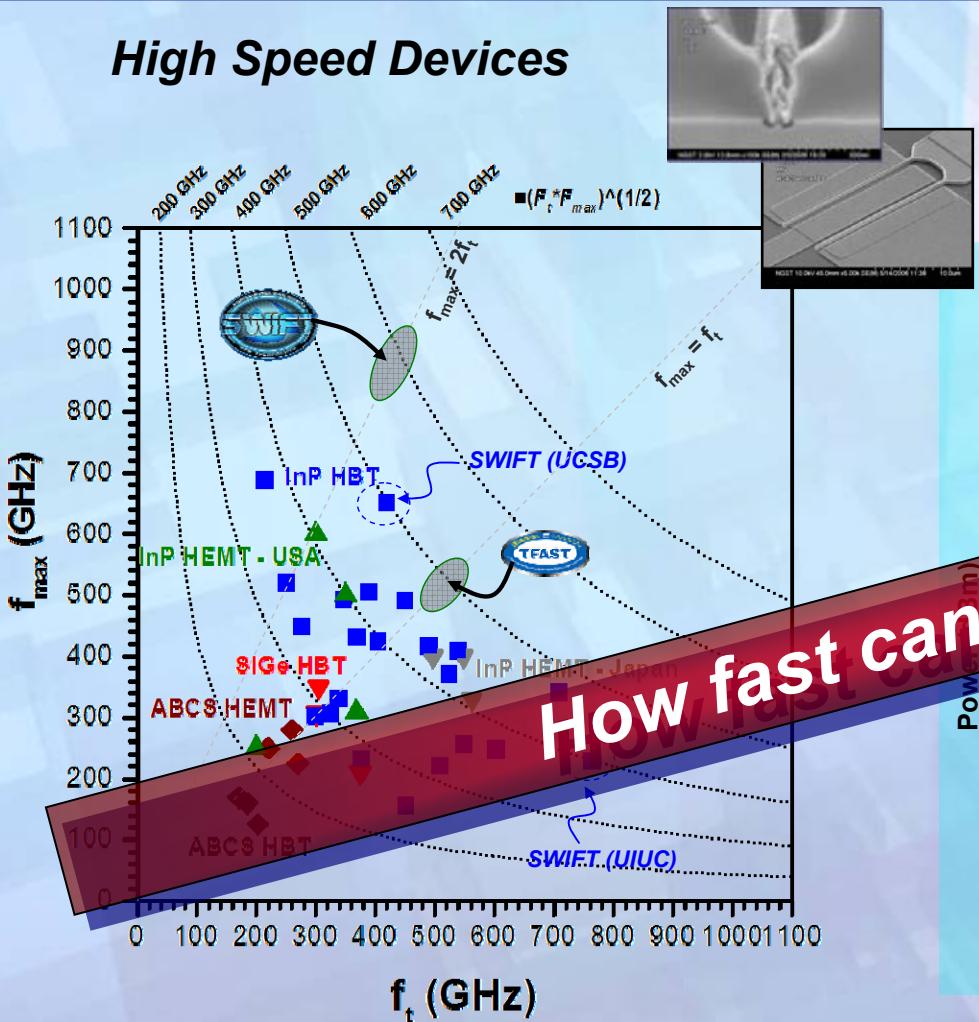


NORTHROP GRUMMAN

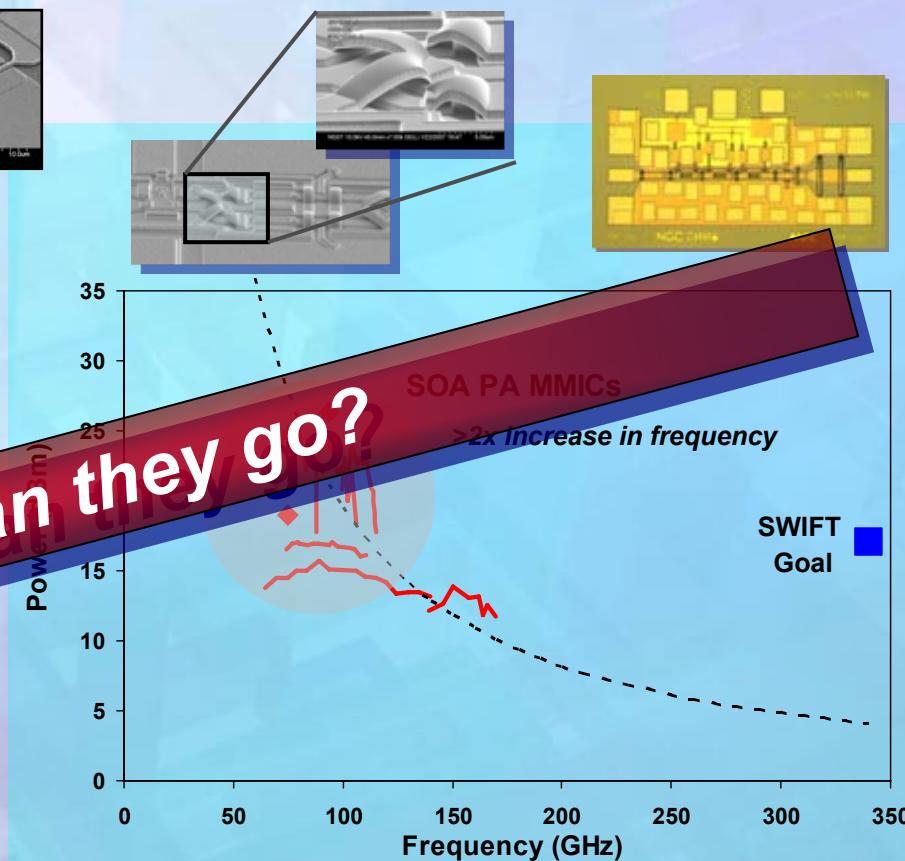
Compact.

Transistor Electronics

High Speed Devices



High Speed MMICs



Big Advantage: Integration & Interconnects
Big Challenge: f_{max} , Circuit Design



SWIFT Accomplishments

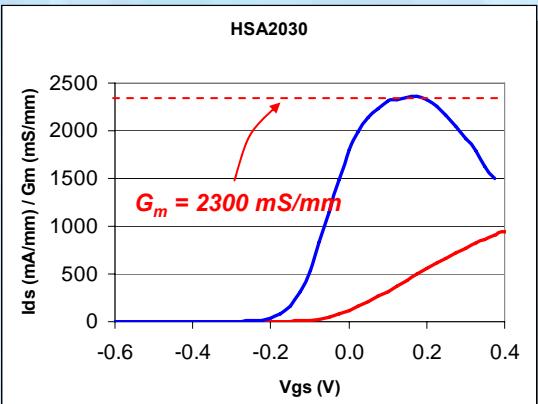
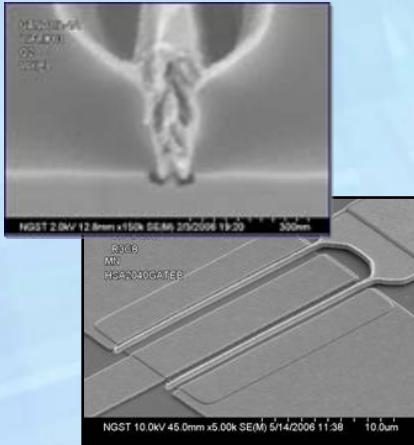
World's Fastest MMICs



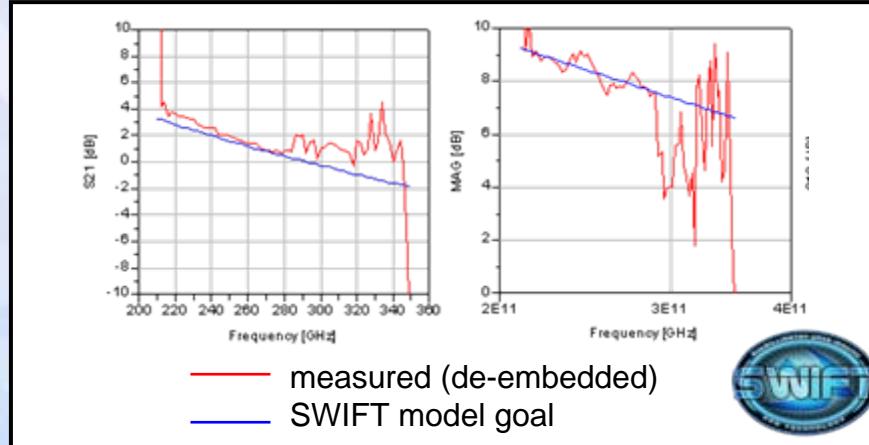
35nm InP HEMT Devices

NORTHROP GRUMMAN

35nm gate of InP HEMT with record $G_m = 2300\text{mS/mm}$

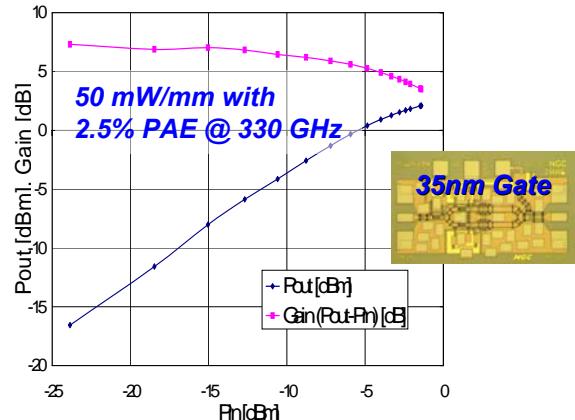


MAG@340 GHz > 6 dB for both model & measured results

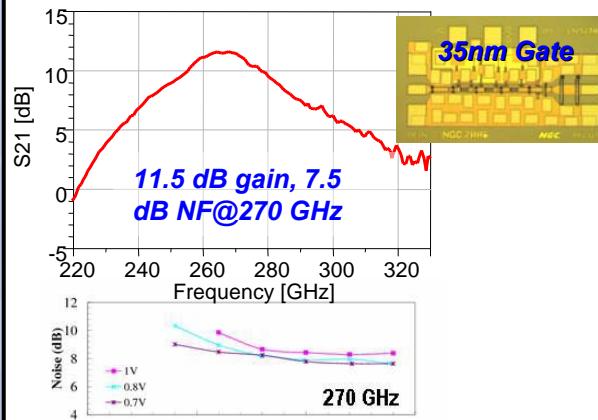


World Record Sub-MMW MMICs ("s-MMIC")

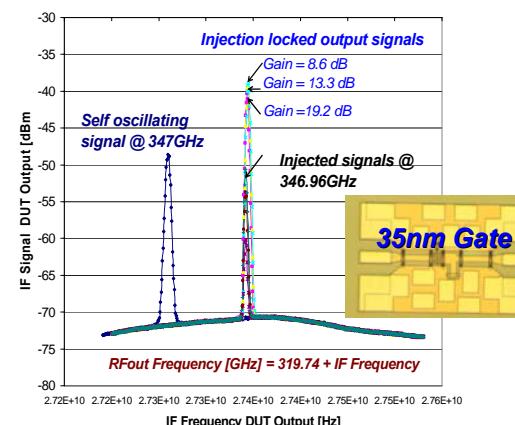
3-stage Power Amplifier @ 330 GHz



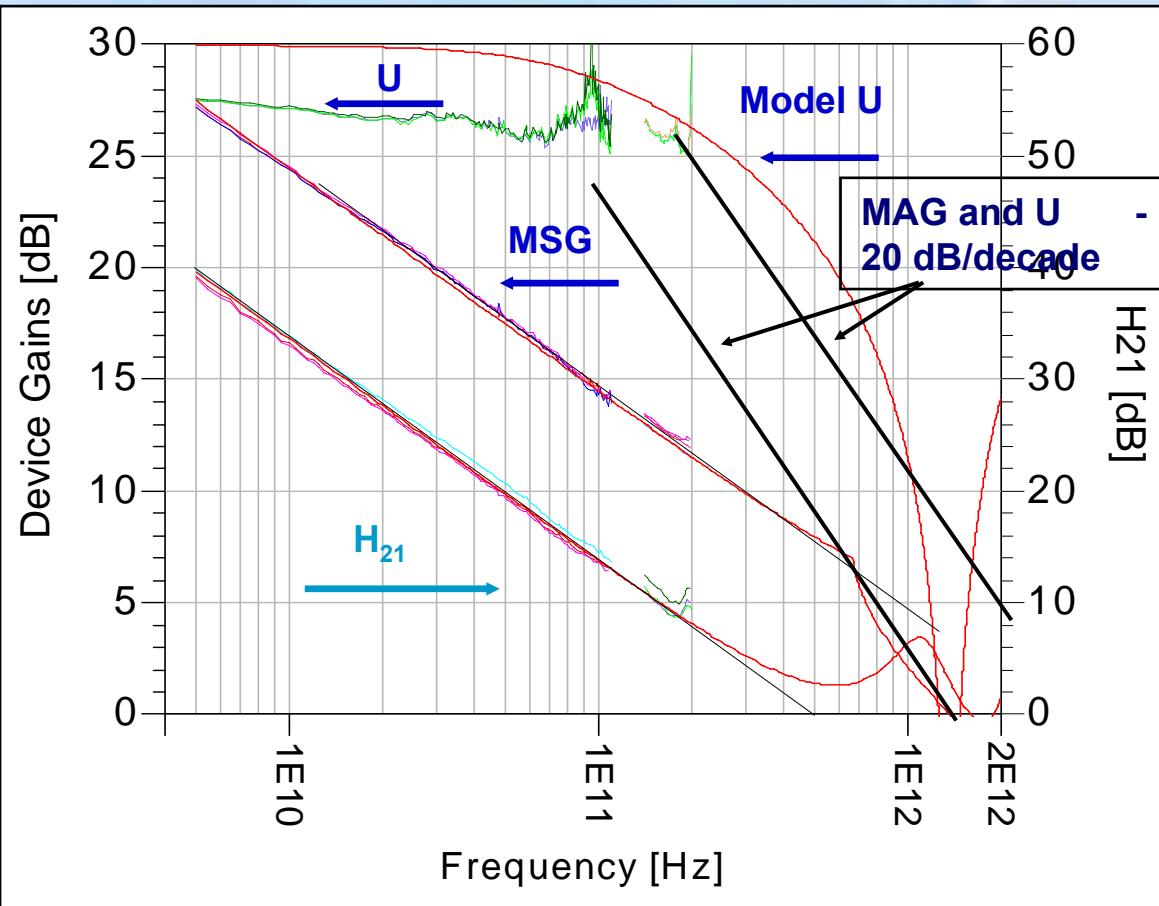
3-stage Low Noise Amplifier @ 270 GHz



First s-MMIC: a 347GHz HEMT VCO



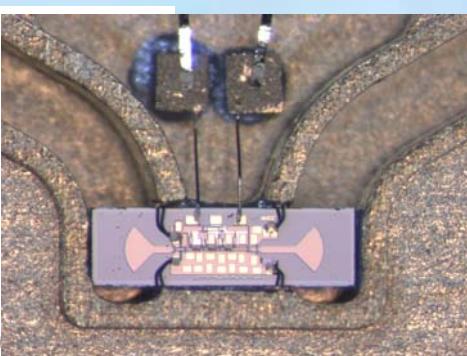
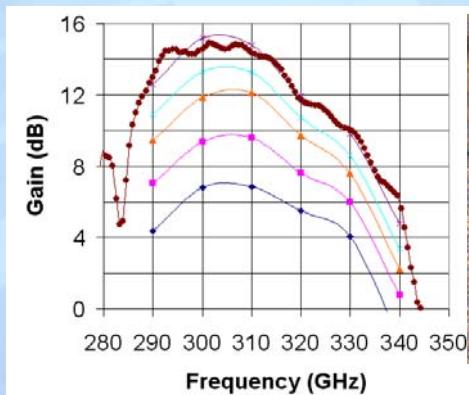
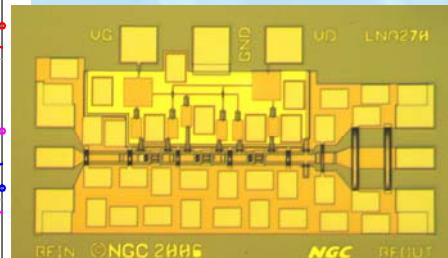
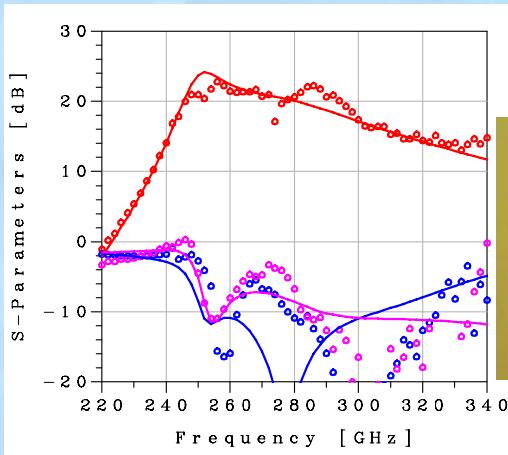
Fmax



- 4 finger 60 μm device
 - 1-110 GHz; 140-220 GHz
- TRL cal structure used
 - better 140-220 GHz measurement accuracy
- U follows predicted model
- MSG follows both trend & predicted model
- H₂₁ follows both trend & predicted model

- Fmax ~ 1.2 THz; fT ~ 500 GHz
- Measurements extended to 200 GHz follow gain and H₂₁ trends

Highest Frequency Circuits



Features

- Sub 50 nm gate InP HEMT
- 2-mil InP thickness with compact vias
- 3-stage MMIC LNA ($2f = 20 \mu\text{m}$ per stage)
 - 21 dB gain @ 280 GHz (7 dB/stage)
 - 17 dB gain @ 300 GHz (5.7 dB/stage)
 - 15 dB gain @ 340 GHz (5 dB/stage)
 - Some LNAs show 18 dB gain @ 340 GHz
- JPL designed integrated radial probes & WR3 fixture (cutoff < 285 GHz & > 340 GHz)
- Amplifier fixture measurements taken and referenced to waveguide flange
 - 4-6 dB loss due to transitions & waveguide
 - fixture & on-wafer measurement data matches from 290 – 330 GHz

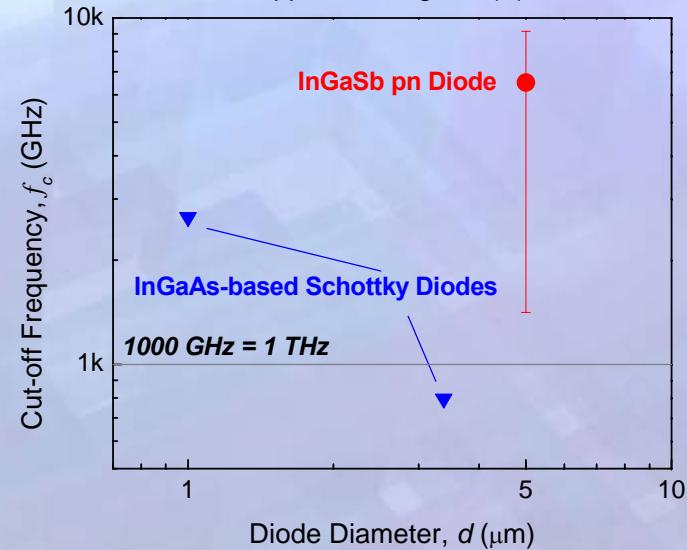
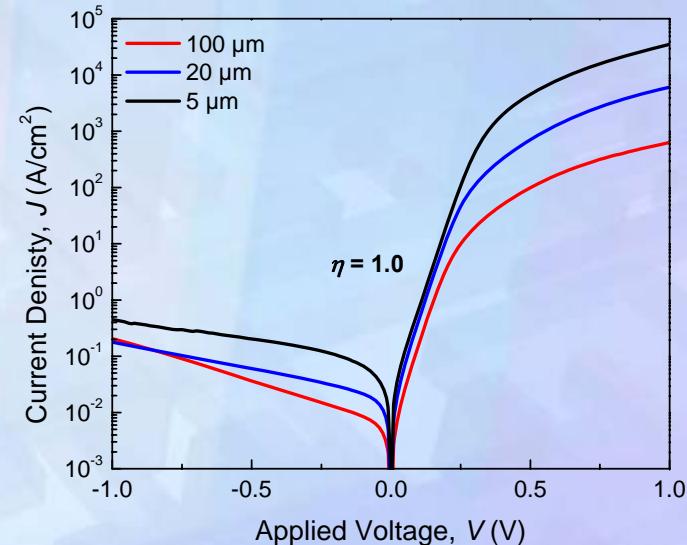
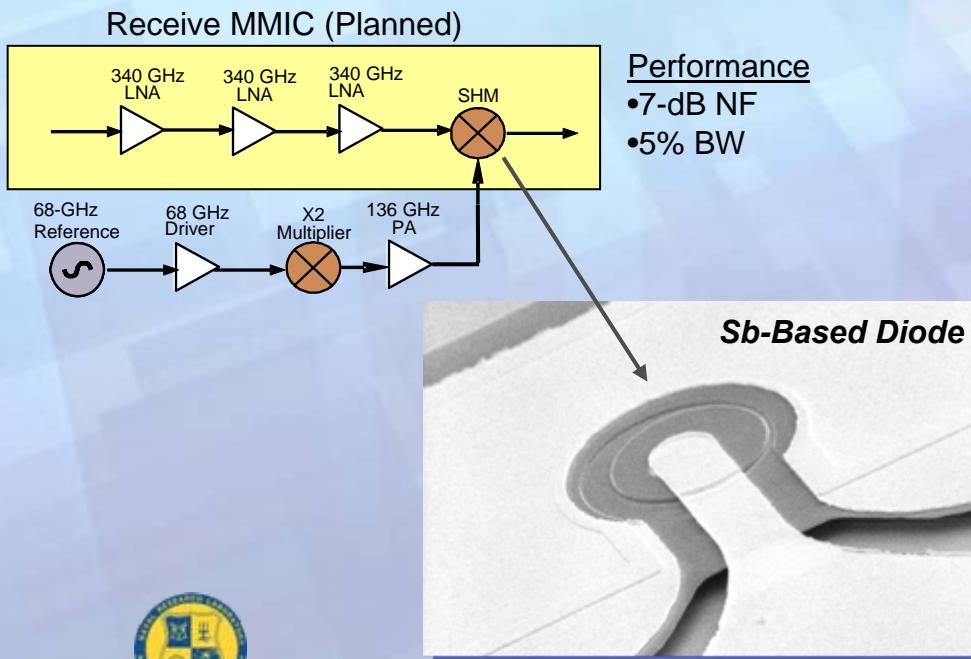
- Highest frequency MMIC amplifier ever demonstrated
- Excellent match to simulation validates model
- Fixtured amplifier validates measurement
- Validates THz f_{max} Transistor claim



THz Sb-Based Diodes for Sub-Harmonic Mixers

InGaSb/InAlAsSb PN Diodes

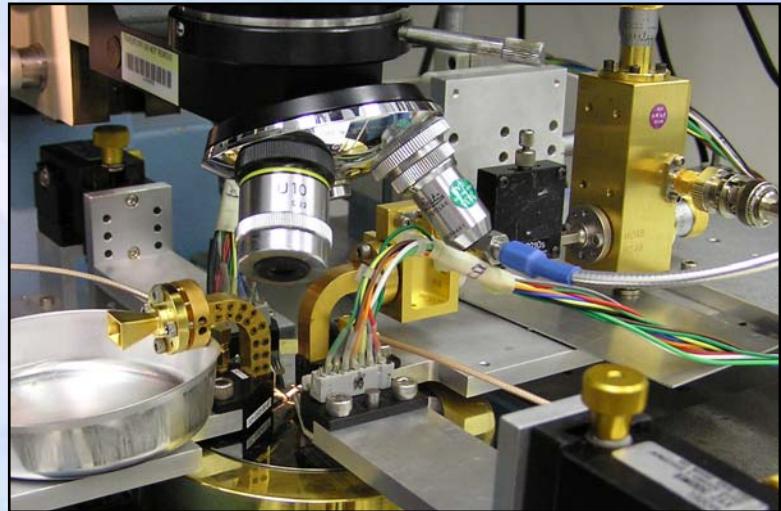
- Excellent ideality factor, $\eta = 1.0$
- Relatively low reverse-bias leakage at low voltage
- Extracted series resistance of 1Ω for a $5 \mu\text{m}$ diameter diode
- Cut-off frequency from S-parameter extracted RC is 1.5 - 9 THz (best fit results in 6.5 THz)



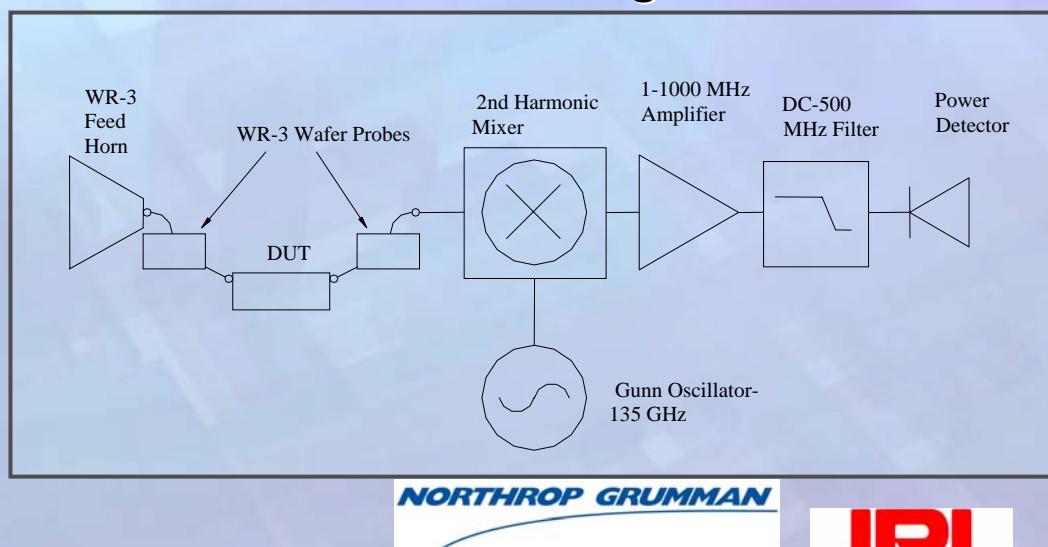
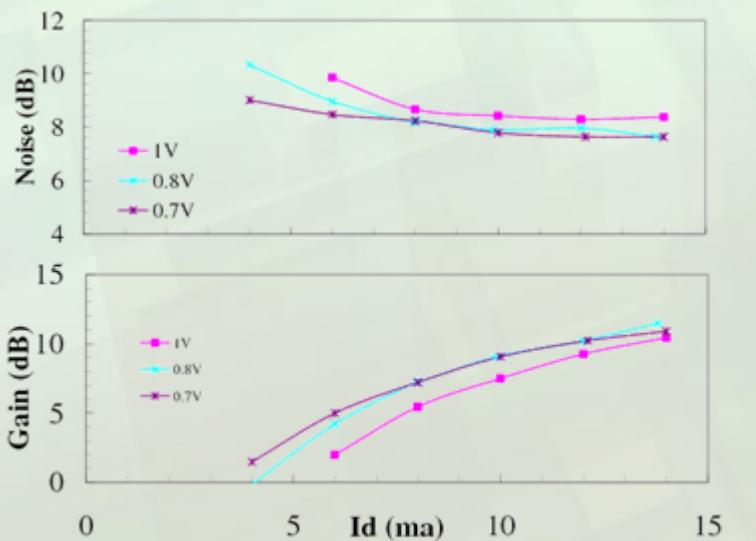
Sub-MMW Metrology: Another DARPA-Hard Challenge

Things that don't exist at 340 GHz...

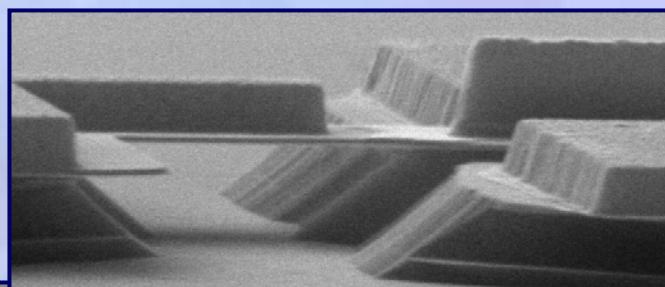
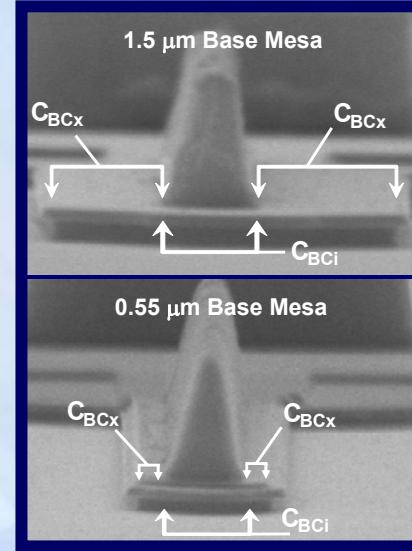
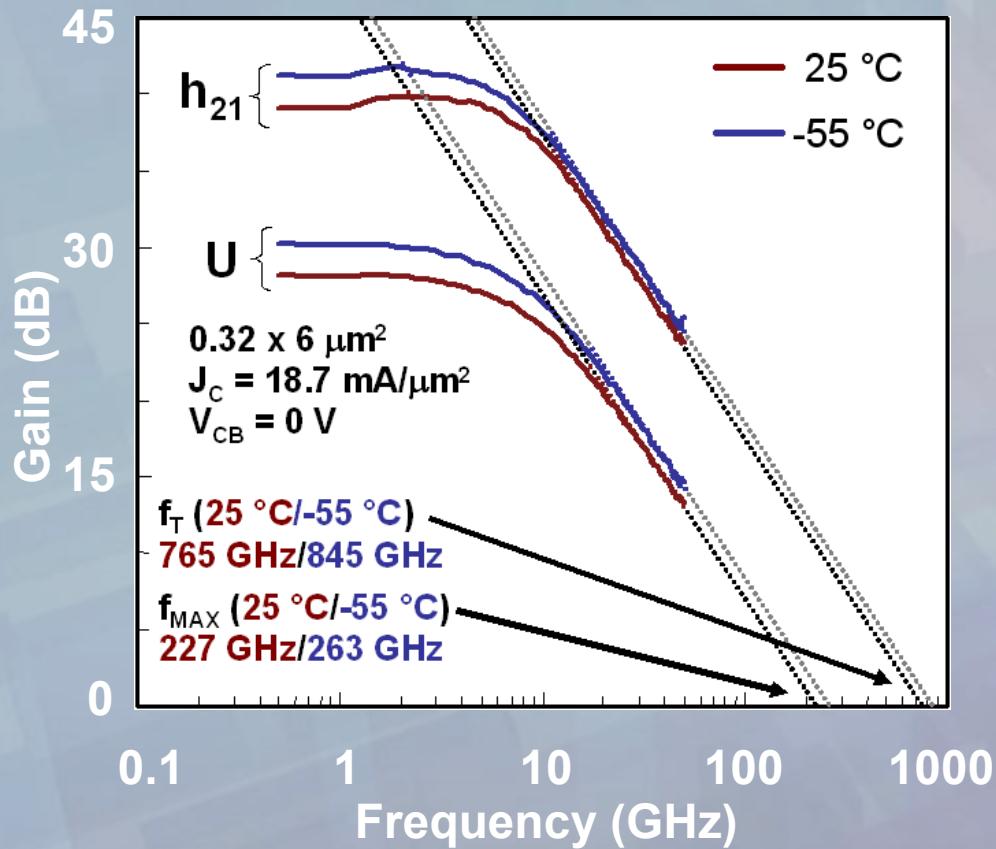
- Isolators
 - Impedance control for power and noise measurements
- Rotary vane attenuators
 - Calibrated loss
- Low loss couplers
 - In-situ power calibrations
- Low loss probes
 - De-embedding noise measurements
- Power amplifiers
 - Input power margin in power measurement
- Impedance tuners
 - Noise/load pull measurement



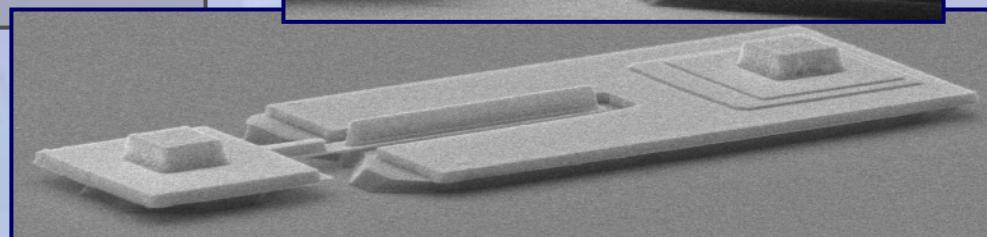
330 GHz Noise Figure Test Set



World's Fastest Transistor



Reduce
base
contact
junction
area



μ -bridge Base Contact

HIFIVE



High Frequency Integrated Vacuum Electronics (HIFIVE)



SOA Today

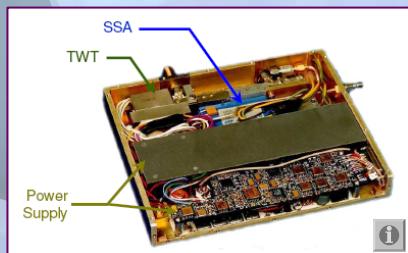
- 220 GHz
- 5 W*
- Not integrated
- * In development

EIK, CPI Canada

Today:
*High frequency sources
are large, expensive,
and performance-limited*

HIFIVE Phase II

- 220 GHz
- 50 W
- “MPM” level of integration (compact module)*
- 250 W-GHz Power bandwidth product



*MPM = Microwave Power Module

Objective

Develop the first all-integrated (“chip-scale”) vacuum electronic devices for high-power millimeter-wave sources

Technologies

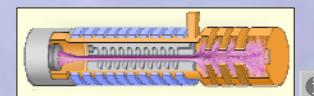
- Si micromachining
- High aspect-ratio interaction structures
- Integrated, high current density cathodes

Impact

- High bandwidth, LPI communication systems
- High-resolution radar
- Manufacturable vacuum electronics process based on standard MEMS rather than custom & expert machining

HIFIVE Phase III

- 220 GHz
- 50 W
- Fully integrated*
- 500 W-GHz Power Bandwidth product



* Cathode, gun, interaction structure, collector, driver, HV source

COVERT: Small, high power-bandwidth source

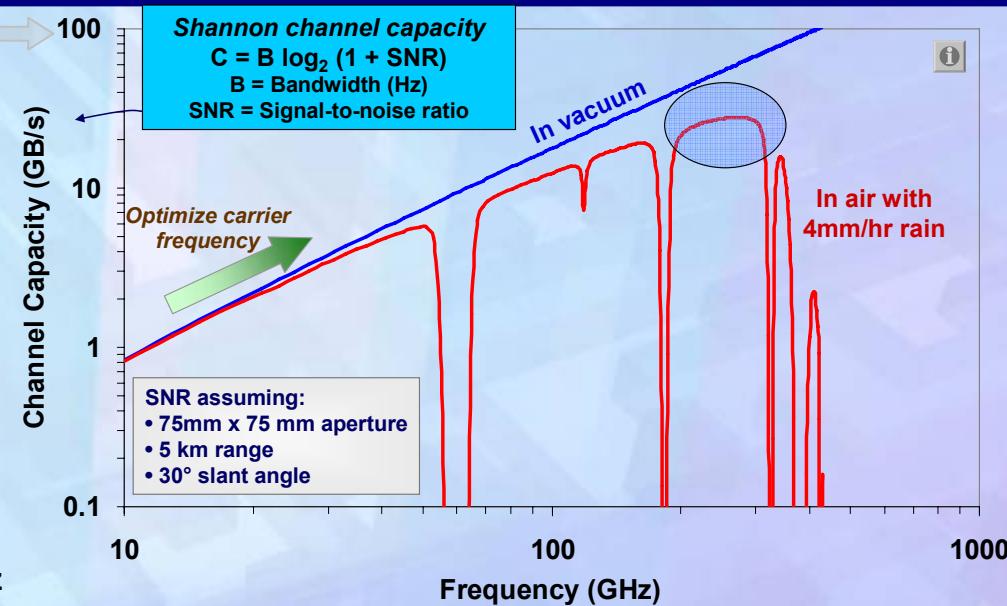
Program Impact

Source for high bandwidth datalinks

- Offers ~10x higher Shannon capacity than Ku-band (for same antenna area), or
- Offers ~100X smaller antenna area than Ku-band (for same Shannon capacity)

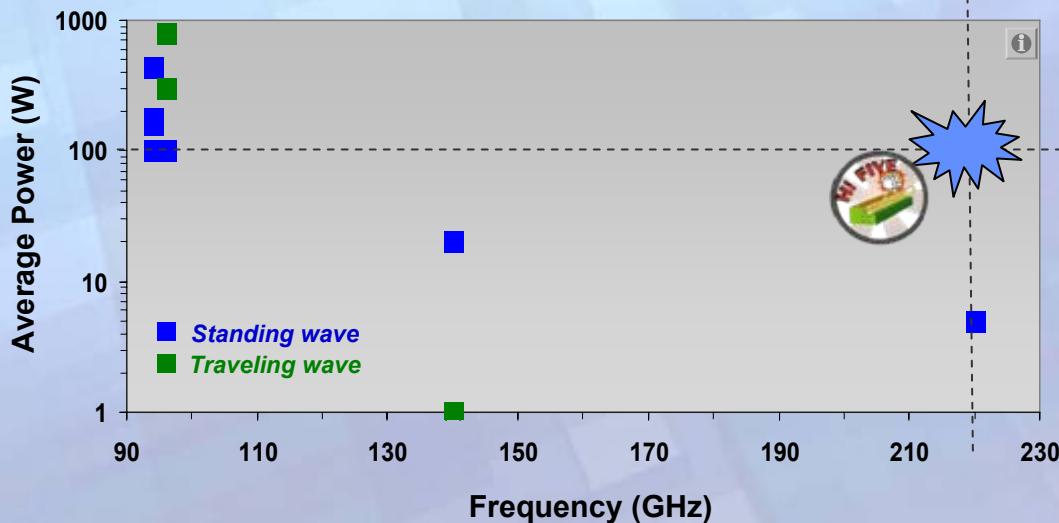


Today: UAVs use Ku- band MPMs for tactical comms



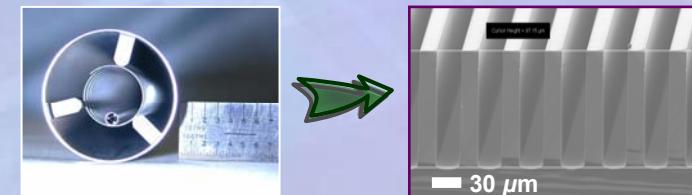
First high power source above 200GHz

- Power density / power-bandwidth product at 220GHz comparable to the best available at any frequency



Micromachined TWT process

- End reliance on custom machining
- Extensible to wide range of frequencies



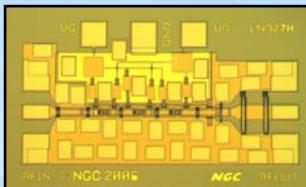
Tactical communications

- Commercial sources and receivers currently are virtually unknown at 220GHz

Technical Challenges

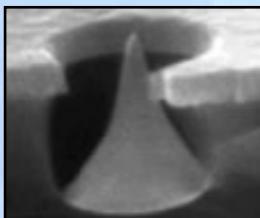
High Power MMIC Driver

- Accommodate relatively low VE gain at 220 GHz



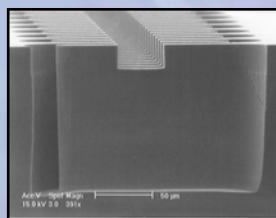
High Current Density, Long Life Cathodes

- High unfocused current density ($\sim 100\text{A}/\text{cm}^2$)
- Life > 10^4 hrs



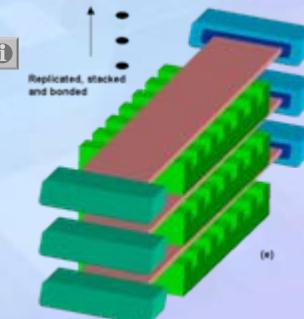
High Precision Micromachined Fabrication and Integration

- Achieve required smoothness & aspect ratio
- Material/technology/process compatibility
- Heterogeneous integration
- Maintain high vacuum



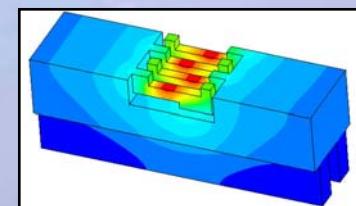
High Aspect-Ratio Devices

- High efficiency interaction structures
- Single vs. multi-beam topologies
- Magnetic compression to achieve high aspect ratio beam ($N \sim 100$)
- Mitigation of parasitic oscillations



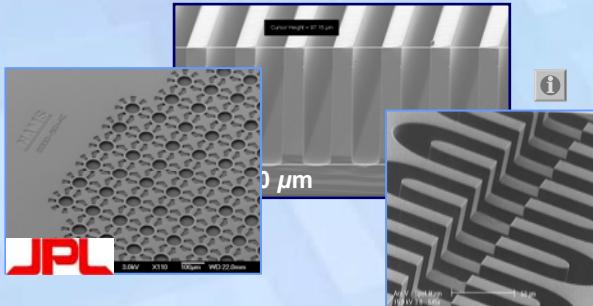
High Efficiency Thermal Management

- Mode confinement / reduction of beam interception
- Aggressive thermal management (mat'l's and structures)



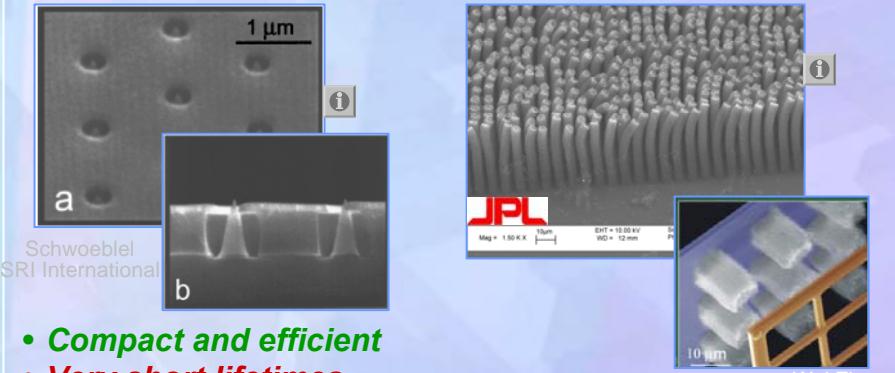
Why Now? HIFIVE Enablers

Micromachining Approaches Achieving Fine Surface Smoothness and High Aspect Ratio



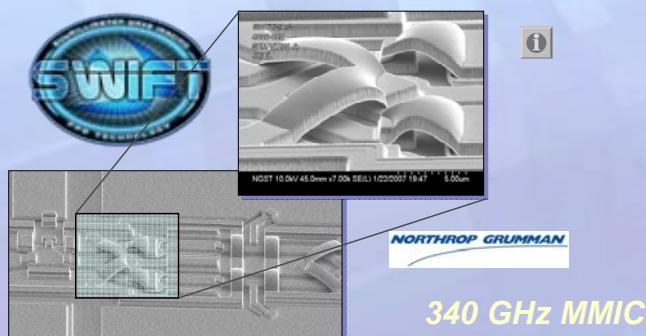
- High precision machining of interaction structures
- Structures susceptible to outgassing adsorption
- Depth of structure difficult for many techniques

Novel Field Emitter Array Cathodes with Improved Current Density



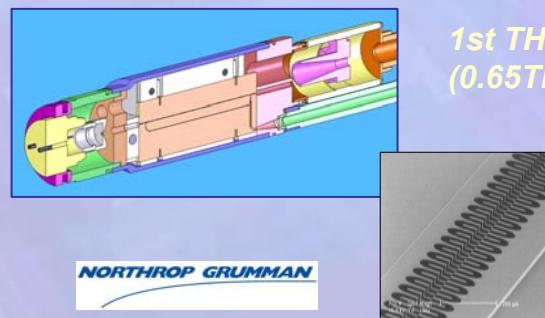
- Compact and efficient
- Very short lifetimes
- Further increase in current densities needed

High Frequency MMIC Process



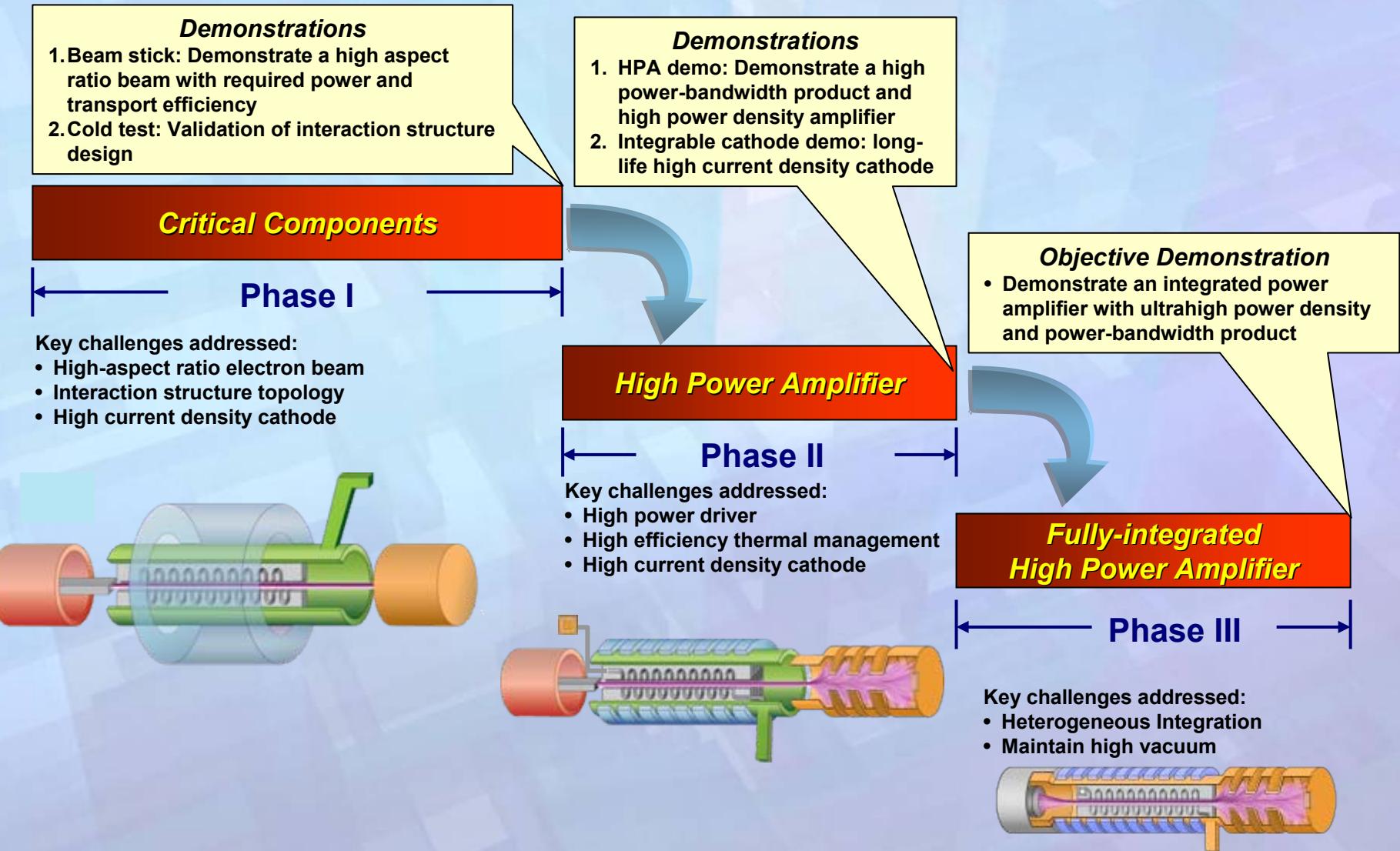
- Frequency of operation now well beyond 220GHz
- Need to increase power
- Integrating the device is difficult (~6dB loss)

THz Frequency TWTA Demo



- High precision machining at frequency
- Round beam
- Lower frequency structure more difficult

Program Schedule





Program Metrics

Metric	Unit	SOA	Phase I	Phase II	Phase III
Go/No Go Metrics					
Beam voltage	kV		20		
Cathode current density ⁽¹⁾	A/cm ²	10	750		
Beam aspect ratio ⁽²⁾		1	25		
Beam transport efficiency	%		95		
Center frequency accuracy	%		<u>±2</u>		
P _{out} ⁽³⁾	W	5 ⁽⁴⁾		50	50
Bandwidth	GHz	0.4 ⁽⁴⁾		5	5
Power-bandwidth product	W*GHz	2 ⁽⁴⁾		250	500
Efficiency ⁽⁵⁾	%	<1%		5%	5%
Total current ⁽⁶⁾	mA	100		250 ⁽⁷⁾	250 ⁽⁸⁾
Other Metrics					
Spectral purity ⁽⁹⁾	dBc			-50	-50
Driver output power ⁽³⁾	mW	50 ⁽⁴⁾		50	50

(1) Measured in beam stick; pulsed

(2) Defined as sum of the width of all beams/thickness of beams

(3) Average power at 220GHz, measured external to device

(4) Projected performance at 220GHz; research device

(5) Total wallplug efficiency

(6) Measured at cathode surface, for 1000 hours life

(7) As a component

(8) Integrated into HPA

(9) Measured 250kHz from carrier



HIFIVE Kickoff!

